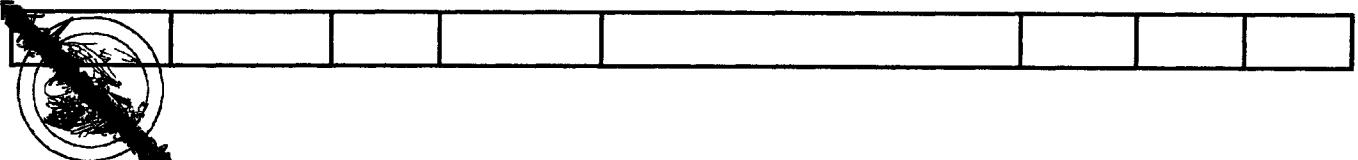


The diagram illustrates a phylogenetic tree with the following key features:

- Root:** Located at the top left, representing the common ancestor of all organisms.
- Major Clades:**
 - Euk:** Eukaryotes, represented by a large cluster of closely related species.
 - Bacteria:** Bacteria, represented by a large cluster of closely related species.
 - Arch:** Archaea, represented by a cluster of species distinct from bacteria.
 - RER:** Rickettsia-like Endosymbiont, a specific group within the bacterial domain.
 - RER-like:** RER-like, indicating other bacteria that share similar characteristics.
- Horizontal Bar:** A thick black line at the bottom right, oriented diagonally upwards and to the right, serves as a reference for the direction of evolutionary divergence.

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JAPAN 2003-340921 09/30/2003

If Required, Foreign Filing License Granted: 09/28/2006

The country code and number of your priority application, to be used for filing abroad under the Paris Convention, is **US10/573,968**

Projected Publication Date: 01/04/2007

Non-Publication Request: No

Early Publication Request: No

Title

Optical recording medium and data recording device

Preliminary Class

428

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Since the rights granted by a U.S. patent extend only throughout the territory of the United States and have no effect in a foreign country, an inventor who wishes patent protection in another country must apply for a patent in a specific country or in regional patent offices. Applicants may wish to consider the filing of an international application under the Patent Cooperation Treaty (PCT). An international (PCT) application generally has the same effect as a regular national patent application in each PCT-member country. The PCT process **simplifies** the filing of patent applications on the same invention in member countries, but **does not result** in a grant of "an international patent" and does not eliminate the need of applicants to file additional documents and fees in countries where patent protection is desired.

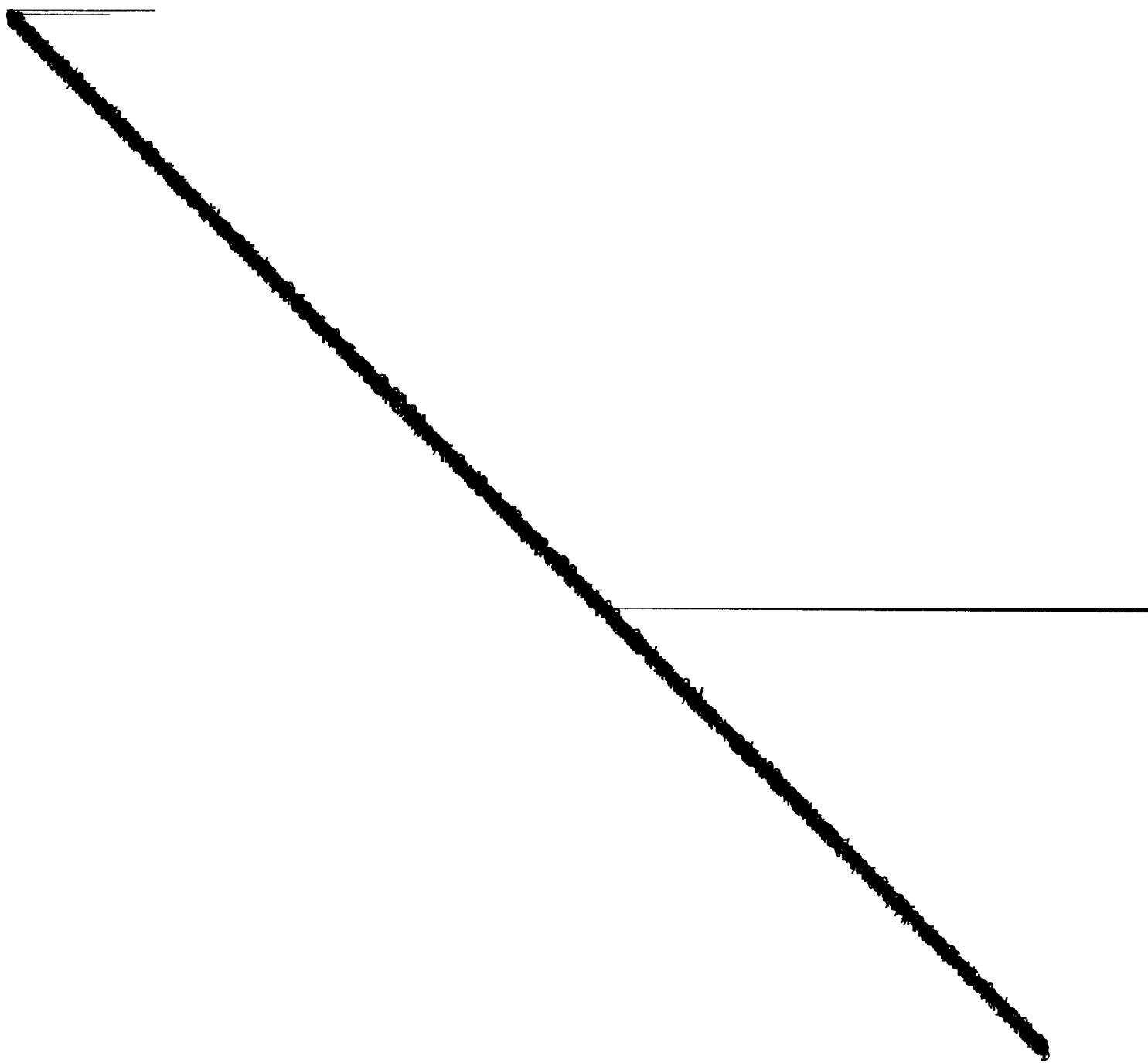
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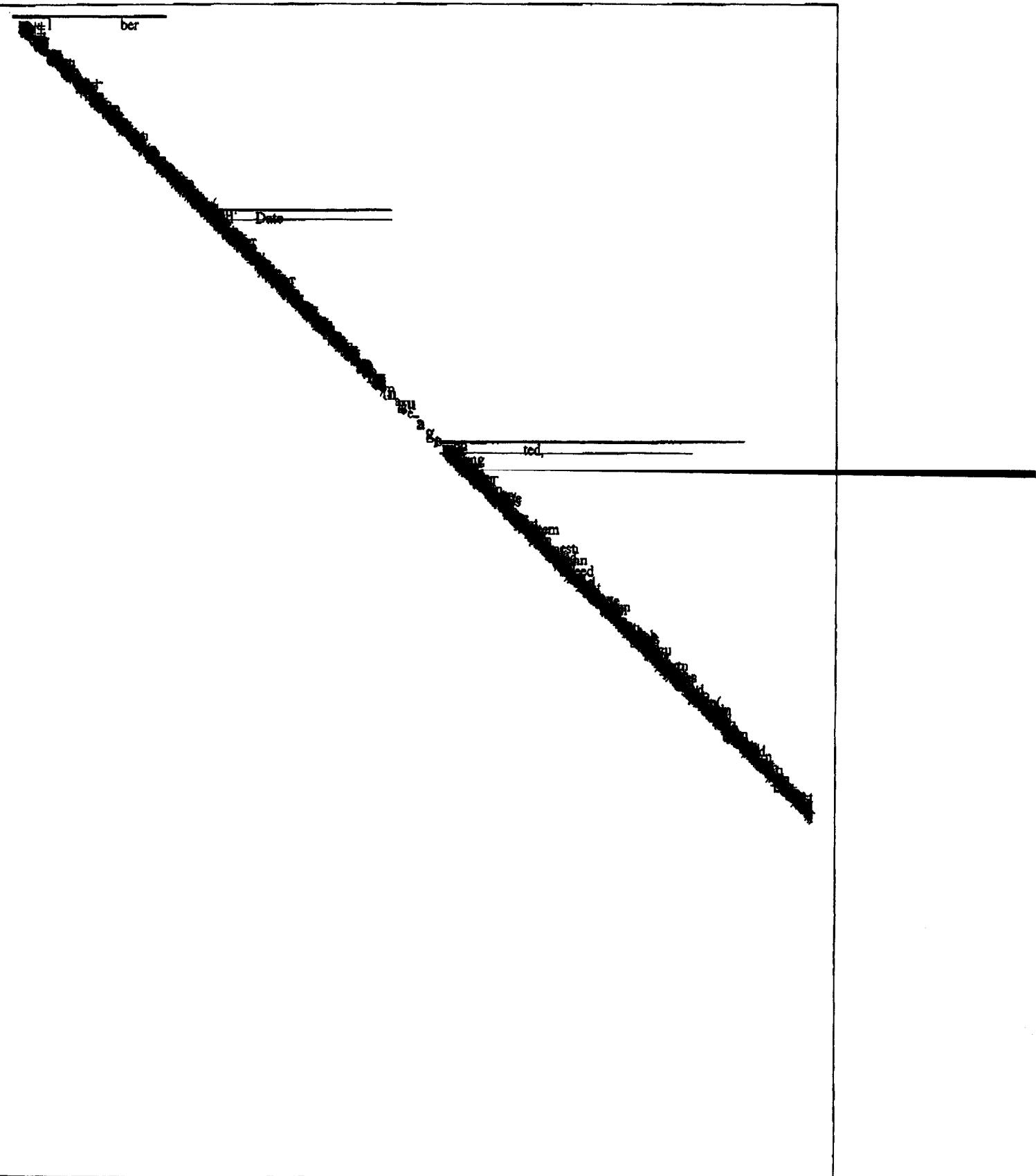
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